

IN THE SPECIFICATION:

Please replace paragraph [0003] with the following amended paragraph:

[0003] Epoxy-based resins are generally photochemically cured by adding an onium salt photoinitiator to the epoxy-based resin and exposing the resulting formulation to UV radiation. The UV radiation photolyzes the photoinitiator to generate an acid, such as hexafluoroantimonic acid (HSbF_6), hexafluorophosphoric acid (HPF_6), tetrafluoroboric acid (HBF_4), or triflic acid ($\text{CF}_3\text{SO}_3\text{H}$), that yields a proton that attacks the oxirane oxygen of the epoxy group and results in cationic curing of the epoxy-based resin. Onium salt photoinitiators that generate hexafluoroantimonic acid are preferred, as hexafluoroantimonic acid typically cures epoxy-based resins ~~fasters~~ faster than other acids that have been tested.